

INFORMATION DISCLOSURE CITATION IN AN APPLICATION		ATTY. DOCKET NO. 60188-634		SERIAL NO.			
(PTO-1449)		APPLICANT Endo MASAYUKI, et al.					
		FILING DATE August 20, 2003		GROUP			
U.S. PATENT DOCUMENTS							
EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Code(s) (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear		
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FOREIGN PATENT DOCUMENTS							
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						Yes ~	No
MW		JP-2001-316863 (w/ English Abstract)	11/16/2001	TOK CORP.	—	✓	
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.					
MW		M. Switkes et al., "Immersion lithography at 157 nm", J. Vac. Sci. Technol., B19(6), (2001), pp. 2353-2358.					
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